

DOCKET NO.: 240882US0

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF

TOMOHISA KONNO ET AL : EXAMINER: RACHUBA, MAURINA T.

SERIAL NO.: 10/626,521

FILED: JULY 25, 2003 : GROUP ART UNIT: 3723

FOR: AQUEOUS DISPERSION FOR CHEMICAL MECHANICAL POLISHING AND PRODUCTION PROCESS OF SEMICONDUCTOR DEVICE

AMENDMENT

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Office Action dated November 13, 2006, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 7 of this paper.